

PATENT
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Atty. Dkt. No. INFNWB0060

IN THE CLAIMS:

Please cancel claims 1-3 and 7-15 without prejudice and amend the claims as follows:

1-3. (Canceled)

4. (Currently Amended) ~~The programmable read-only memory cell of claim 2,~~
A programmable read-only memory cell, comprising:

a source electrode;

a drain electrode;

a channel layer formed between the source electrode and the drain electrode;

a floating gate isolated from the channel layer; and

a selection gate isolated from the channel layer, wherein the selection gate and the floating gate are arranged on opposite sides of the channel layer, and wherein a first insulator layer is arranged between the floating gate and the channel layer and a second insulator layer is arranged between the selection gate and the channel layer;

wherein the floating gate is arranged at least partly in a trench of a substrate, wherein the trench is formed between the source electrode and the drain electrode, and wherein the floating gate is electrically insulated from the substrate; and

wherein a trench capacitor is formed in the substrate, an inner electrode of said trench capacitor being formed by the floating gate and an outer electrode of said capacitor being formed by a first diffusion region.

5. (Original) The programmable read-only memory cell of claim 4, wherein the first diffusion region is formed within a second diffusion region and the second diffusion region is formed within a third diffusion region, the second diffusion region having a complementary doping with respect to the first diffusion region and with respect to the third diffusion region.

6. (Original) The programmable read-only memory cell of claim 4, wherein the first diffusion region of the read-only memory cell has an overlap region with one or

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more first diffusion regions of two read-only memory cells of a matrix-type arrangement of read-only memory cells that are directly adjacent in a direction perpendicular to a word line, and wherein the overlap region forms an electrically conductive connection between the first diffusion regions of a plurality of read-only memory cells in a series.

7-15. (Canceled)

16. (Currently Amended) ~~The programmable read-only memory cell of claim 15,~~
further A programmable read-only memory cell, comprising:

a floating gate disposed in a trench of a substrate;

a channel layer formed over the floating gate, connecting a source electrode to a drain electrode;

a selection gate disposed above the channel layer;

a first insulator layer disposed between the floating gate and the channel layer;

a second insulator layer disposed between the selection gate and the channel layer;

an insulator layer disposed between the floating gate and the substrate; and

a trench capacitor, formed in the substrate, comprising an inner electrode formed by the floating gate and an outer electrode formed by a first diffusion region disposed between the insulator layer and the substrate.

17. (Original) The programmable read-only memory cell of claim 16, further comprising:

a second diffusion region surrounding the first diffusion region; and

a third diffusion region surrounding the second diffusion region, wherein the second diffusion region has a complementary doping with respect to the first diffusion region and with respect to the third diffusion region.

18. (Original) The programmable read-only memory cell of claim 17, wherein the first diffusion region has one or more overlap regions with one or more adjacent first diffusion regions of adjacent read-only memory cells in a direction perpendicular to a

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word line, and wherein the one or more overlap regions form an electrically conductive connection between adjacent first diffusion regions.

19. (Original) The programmable read-only memory cell of claim 17, wherein the channel layer is formed as an epitaxial layer having an n-type doping, and wherein the channel layer is isolated from the floating gate and the selection gate.

20. (Original) The programmable read-only memory cell of claim 17, wherein the source electrode and the drain electrode are formed at least partly on a surface of a substrate.